

# Surface roughness and size effects of thin gold films on mica

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We report measurements of the topography of a gold film deposited on a mica substrate using scanning tunneling microscope (STM), and measurements of the conductivity  $\sigma$  of the film performed between 4 and 300 K. From images obtained with the STM running in air in the constant current mode of a gold sample 70-nm-thick deposited under UHV on a mica substrate preheated to 300 °C, we compute the average autocorrelation function (ACF) that characterizes the surface of the film in the scale of  $(\text{Formula presented})$  and determine by least-squares fitting the parameters  $\sigma$  (rms. amplitude) and  $\lambda$  (lateral correlation length) corresponding to an exponential that best describes the average ACF data. Using an exponential representation of the ACF, the parameters  $\sigma$  and  $\lambda$  determined from STM measurements, and a modified version of the theory of Sheng, Xing, and Wang recently proposed [R. C. Munoz et al., J. Phys.: Condens. Matter 11, L299 (1999)], we calculate the temperature dependence of the bulk resi